

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Patent Application of:
Hiroki YOSHIKAWA et al.

Application No.: 10/811,924

Confirmation No.: 063156

Filed: March 30, 2004

Art Unit: 1756

For: PHOTOMASK BLANK, PHOTOMASK, AND
METHOD OF MANUFACTURE
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Examiner: S. D. Rosasco

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated October 20, 2006, please amend the above-identified U.S. patent application as follows:

Remarks/Arguments begin on page 2 of this paper.